# Equipment Corporation

enabling tomorrow's technologies™

## 13<sup>th</sup> Annual NYC Investor Summit 2024

December 17<sup>th</sup>, 2024



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## Safe Harbor Statement

The Private Securities Litigation Reform Act of 1995 provides a "safe harbor" for forward-looking statements. Certain information included in this press release (as well as information included in oral statements or other written statements made or to be made by CVD Equipment Corporation) contains statements that are forward-looking. All statements other than statements of historical fact are hereby identified as "forward-looking statements, "as such term is defined in Section 27A of the Securities Exchange Act of 1933, as amended, and Section 21E of the Securities Exchange Act of 1934, as amended. Such forward looking information involves a number of known and unknown risks and uncertainties that could cause actual results to differ materially from those discussed or anticipated by management. Potential risks and uncertainties include, among other factors, market and business conditions, the success of CVD Equipment Corporation's growth and sales strategies, the possibility of customer changes in delivery schedules, cancellation of, or failure to receive orders, potential delays in product shipments, delays in obtaining inventory parts from suppliers and failure to satisfy customer acceptance requirements, competition in our existing and potential future product lines of business, including our PVT systems; our ability to obtain financing on acceptable terms if and when needed; uncertainty as to our ability to develop new products for the high power electronics market; uncertainty as to our future profitability; uncertainty as to any future expansion of the Company; uncertainty as to our ability to adequately obtain raw materials and components from foreign markets in light of geopolitical developments; and other risks and uncertainties that are described in the Company's Annual Report on Form 10-K for the year ended December 31, 2023 and the Company's other filings with the Securities and Exchange Commission. For forward-looking statements in this release, the Company claims the protection of the safe harbor of the Private Securities Litigation Reform Act of 1995. The Company assumes no obligations to update or supplement any forwardlooking statements whether as a result of new information, future events or otherwise. Past performance is not a guarantee of future results.

## Key Markets







EV Battery Materials/Energy Storage

Industrial Coating Equipment © 2024 CVD Equipment Corporation | All rights reserved

## **CVD** Equipment Corporation

CVDE designs and manufacturers a broad range of chemical vapor deposition, thermal processing and physical vapor transport equipment to Aerospace & Defense, High Power Electronics, Energy Storage, and Industrial Materials markets

#### About CVDE:

- Manufacture application-specific and turn-key systems for Advanced & Energy Efficient Materials
- Serving customers with demanding material performance requirements
- Provide relentless commitment to customer satisfaction
- Deliver competitive advantage to our customers through innovation, market focus and operational excellence



### **CVDE's Value Proposition:**

- 40+ Years Providing Equipment & Process
   Solutions to blue chip leaders, innovative startups
   & leading research institutes
- Decades of experience in Aerospace & Compound Semiconductor applications
- Launched six new products in 2024
- Vertically Integrated Manufacturing
- Robust customer engagement and global account management
- High Touch Customer Service



## **CVD Equipment Corporation At a Glance**

- We have served our growing customer base for over 40 years
- Focused on strategic markets that have significant growth potential
- Providing enabling and reliable equipment & solutions to our customers
- Developed multiple products in each marketplace
- Six new product launches in 2024
- Proven track record of customer engagement and satisfaction through on-time delivery and customer support



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## Financial and Operational Snapshot



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### Infrared Heating Technology

### Resistive Heating Technology

# Market Overview

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## Growth, Strategic & Emerging Markets

## **Advanced and Energy Efficient Materials**



**Aerospace & Defense** 

Demand for **ceramic matrix composite materials** (CMCs) for use in gas turbine engines to enable greater fuel efficiency and in hypersonic systems requiring ultra-high temperature materials for survivability.



**High Power Electronics** 

EVs driving the demand for silicon carbide wafers required for devices used for power distribution and charging. Higher power density and efficiency than silicon-based devices increases EV range and enables faster charging times.



#### **EV Battery Materials**

EVs driving the demand for advanced battery materials. Coating graphite anode powder with silicon increases energy density, enabling expanded driving range and faster charging times.



#### **Industrial Coating Equipment**

Demand for production **CVD Systems to coat large graphite components with SiC** to support semiconductor market enabling increased durability and lifespan of critical graphite parts used in semiconductor manufacturing processes.

### Inductive Heating Technology

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## Tow Transport Technology

# **Products and Technologies**

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## Aerospace Leading CMC Manufacturing Processes



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**Chemical Vapor Infiltration for Aerospace & Defense** Equipment Corporation

# **CVI** 3500

#### **Benefits & Differentiating Features**

- Five zone furnace with independent zone temperature control
- Temperature uniformity at <+/- 6 °C ٠
- Graphite retort & heating elements ٠
- Heating ramp rate >10 °C per min •
- Furnace cooldown in less than 12 hrs •
- Stainless steel double wall, water ٠ cooled vacuum chamber

- Coaxial gas injection
- Preheat & mixing zone
- Internal pyrolizer
- Heated exhaust line
- Cold trap for ammonium chloride byproduct
- Gantry crane to assist in reactor component and part loading

Thermal Process Processing Chamber Up to 62" ID & up to 1600 °C kW Input 82" tall



10 Torr

Up to 500

Power

5 Zone Control 7 to Resistance Furnace

CVI 3500™ Chemical Vapor Infiltration (CVI) System

CVD Equipment Corporation

2024

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CVD Equipment Corporation Of Ultra High Temperature Coatings

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**CVI200** 

#### **Benefits & Differentiating Features**

- Graphite retort & 3-zone resistive heating
- Stainless steel double wall, water cooled vacuum chamber
- Includes 2 internal chlorinators
- Temperature uniformity +/- 10 °C
- Workpiece Rotation 1- 20 rpm





Thermal Processing Up to 1600 °C



Control 5 to

500 Torr

3 Zone Resistance Furnace



- Internal pyrolizer
- Heated exhaust line
- Cold trap for ammonium chloride byproduct
- Exhaust gas conditioning system with closed loop pH control and recirculation



### CVD Equipment Corporation Chemical Vapor Deposition for Uniform Silicon Coating

# **SiBondCoat 200**<sup>™</sup>

#### **Benefits & Differentiating Features**

- For applying Si layer to 3D surfaces
- Single Chamber Processing (Multi Chamber Option)
- Multiple gas injectors with independent flow control for thickness uniformity
- Capable of direct liquid injection, bubbler source injection, and vapor/gas delivery



RF Induction Heating - Process Temperature up to 1250° C



Substrate Rotation for Improved Deposition Uniformity



- Optional Gas Delivery Cabinets
- Optional Liquid Abatement
   System
- Designed for ease of maintenance

Vertical, Quartz

Vacuum

Chamber



Low Pressure System for Industrial Applications



## SiC/C Fiber Handling Equipment Equipment Corporation

# Fiber Handling System

**Benefits & Differentiating Features** 

- Intelligent Spool/De-Spool System
- Variable Fiber Tow Tension Control
- Vacuum rated chambers for spooling and de-spooling
- Equipped with CVD Equipment's proprietary magnetically coupled drive system
- **Differential pressure** transducers for pressure monitoring
- Equipped with mass • flow-controlled gas purge
- **Door Interlocks and Alarms**
- PC with CVDWinPrC<sup>™</sup>



Variable Fiber Tow Speed Range



**Patent Pending Bi-directional Fuzz Detection** 



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**Fiber Tow** 

Transport

## State-of-the-Art Equipment Addressing SiC Wafer Market



### SiC Crystal Growth - Physical Vapor Transport Systems Equipment Corporation

# **PVT200**

#### **Differentiating Features & Options**

- **Exceptional Process Parameter Controls** for Steady State & Ramp Conditions - Pressure Control +/- 0.5%
- Standard & Custom Coil Designs
- **Custom Quartzware**
- **Crucible Centering**
- Low Pressure Option
- Compatible with Inert & Flammable Gases

- Dynamic Hotzone Temperature Control<sup>™</sup> for Yield Enhancement (2024)
- **MES** Compatible
- Typical 6 Month Delivery ARO
- Vertically Integrated Manufacturing
  - Reducing Customer Cost of Ownership
  - Ensuring Certainty of Lead Times







Temperature Control +/- 0.5 °C up to 2500 °C

Run-to-Run

Repeatability



Matching



System-to-System Compact Footprint



**Dynamic Hotzone** Temperature Control™ **Physical Vapor Transport System** 

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PVT200<sup>™</sup>



## Dynamic Hotzone Temperature Control (DHTC™)

Improved within Process Run, Run-to-Run & System-to-System Temperature Measurement Consistency for 200 mm & 150 mm SiC Physical Vapor Transport Systems

#### Benefits

- Yield Improvement for SiC Crystal Boule Growth by Optimizing Temperature Measurement & Control
- Minimizing Impact of Misalignment from Hotzone Degradation, Assembly, & Loading

#### **Differentiating Features & Options**

- Video Processing Software & Mechanical Hardware for Temperature Measurement Accuracy & Dynamic Temperature Measurement Position Tracking
- Automated Pyrometer Tracking & Alignment to Hotzone
- Offered as an Integration Option with CVDE's PVT200<sup>™</sup>
- An Integration Option Offered for Your Existing PVT System

#### Patent Pending



SiC Crystal Growth Yield Enhancement with DHTC Temperature Measurement & Control

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## Methods for Silicon Battery Anode Materials

### Numerous techniques are employed in the industry to incorporate silicon into graphite anodes

- 1. Dry Milling & Mixing Silicon with Carbon
  - Simple low-cost process
  - Nano silicon readily agglomerates and is not uniformly dispersed <sup>[1]</sup>
- 2. Wet Processing
- 3. Spray Drying
- 4. Chemical Vapor Deposition/Chemical Vapor Infiltration
  - Enables incorporation of silicon onto or into graphite powder
    - CVD deposition of silicon onto carbon powder or growth of silicon nanowires directly onto powder surfaces (OneD Battery Sciences)
    - CVI silicon infiltration within porous, carbon powder scaffolds

Since silicon expands during charge cycling, 1-Dimensional silicon nanowires are being examined to enable greater % silicon incorporation in graphite anode material with reduced susceptibility of electrode damage



[1] https://www.sciencedirect.com/science/article/pii/S258900422100300X#:~:text=However%2C%20the%20lower%20moisture%20level,et%20al.%2C%202013).
[2] https://www.sciencedirect.com/science/article/abs/pii/S000926142300622X#:~:text=Herein%2C%20we%20reported%20a%20facile,mAh/g%20for%20100%20cycles
[3] https://www.sciencedirect.com/science/article/pii/S2772783124000396#bib0037

## CVD Equipment Corporation Chemical Vapor Deposition for EV Battery Materials

# PowderCoat 300

#### **Benefits & Differentiating Features**

- Powder Coating for Deposition of Nanomaterials & Thin Films
- Customizable Process Tumbler
- Tumbler Volume up to 1.2 L

Powder

R&D

Infiltration &

Coating for

- Robust System with Enhanced Process Controls
  - Pressure Control +/- 1%

Hundreds of Microns
Coating Thickness: A few Nanometers to Tens of Microns
Glove Box for Unloading Sample Under Inert Conditions

**Powder Particle Size** 

Distribution: Sub-microns to



3 Zone

Furnace

Resistance



Rotating Tumbler for Uniform Mixing (Speed up to 50 RPM)



Rapid Cool-Down



#### PowderCoat 300<sup>™</sup> Chemical Vapor Deposition System

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## **Chemical Vapor Deposition for EV Battery Materials** Equipment Corporation

# PowderCoat 1104

#### **Benefits & Differentiating Features**

- **Uniform Coating and Deposition** of Nanomaterials & Thin Films
- **Multi-Reactor Chambers for** Parallel or Sequential Processing
- Inconel Chamber: Volume 250L
- **Robust Production System with Enhanced Process Controls** - Pressure Control +/- 1%

- Low Pressure CVD
- Powder Particle Size: Submicron to Hundreds of Microns
- Coating Thickness: A few • Nanometers to Tens of Microns
  - **MES** Compatible
- EGC 1510 HSF Gas Abatement • System







**High Volume** Temperature

Powder Control +/- 1 °C Infiltration & up to 700 °C Coating



**Rotating Tumbler** 

for Uniform Mixing

Rapid 5 Zone Cool-Down Resistance Furnace

PowderCoat 1104<sup>™</sup> **Chemical Vapor Deposition System** 

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## **Chemical Vapor Deposition for CNTs on Foil** Equipment Corporation

# CARBON 300

#### **Benefits & Differentiating Features**

- Production of CNTs on Foil & **Rigid Substrates**
- 350 mm Diameter Quartz Tube
- Custom Quartzware for easy loading/unloading
- Integrated Burn Box for Gas Abatement

- Flammable & Toxic Gas Sensors
- Powered by our CVDWinPrC<sup>™</sup> **Process Control Software**
- Safety Controls •

Heating to

900 °C





Precise Rolling Temperature Furnace/hot load/unload



•

6-Zone Resistance

Rapid Cool-Down



Chemical Vapor Deposition for Industrial Coating Equipment Corporation

# **CVD**4000

#### **Benefits & Differentiating Features**

- Temperature Uniformity at <+/- 6 °C
- **Graphite Retort & Heating Elements**
- Heating Ramp Rate >15 °C per min
- Workpiece Rotation 1 20 rpm
- Furnace Cooldown to 300 °C in less than 12 hrs •
- Preheat & Mixing Zone
- **Internal Pyrolizer**

#### $(\mathbf{I})$ Process Thermal **High Power** Low Pressure Control 1 to Up to 500 Chamber Up Processing 50 Torr to 72" ID & up to 1600 °C kW Input 95" tall Power



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# CVD SDC<sup>®</sup> Gas and Chemical Delivery Solutions

### **SDC<sup>®</sup>** Division of CVD Equipment Corporation

- Manufacturer of Ultra-High Purity (UHP) gas and chemical delivery systems for the semiconductor industry as well as high power electronics, microelectronics, nanomaterial production, and aerospace markets
- Globally recognized supplier, sustaining a leading market position
- Providing critical gas and chemical management systems to industry, R&D facilities, and academia for over four decades
- Supporting our customers with onsite and remote service, preventative maintenance contracts, spares and consumables



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## Vertically Integrated Manufacturing - Built in the USA



#### **Applications Lab**

New materials, coatings and processing techniques through CVD's Application Laboratory

Innovative carbon (CNT, graphene) products for energy storage, and sensing devices

#### Manufacturing

CVD has expanded its internal manufacturing capabilities in 2022 with new machining centers

Vertically-integrated, >95,000 ft<sup>2</sup> of total manufacturing space

#### Quartzware

Our quartzware manufacturing facility can produce prototype designs with rapid turnaround

Substrate paddles, wafer boats, process gas injectors, process tubes, quartz bubblers, bell jars, etc.

#### SDC<sup>®</sup> Gas Storage & Chemical Delivery Systems

Manufacturer of ultra-high purity gas and chemical delivery systems for the semiconductor industry as well as in microelectronics, nanomaterial production and aerospace markets

Vertical integration gives CVD a competitive advantage, reducing customer cost of ownership, ensuring certainty of lead times, and maintaining quality.



## CVD Focus & Investment To Support The Market Growth Opportunity

## **Five Point Initiative**



## Seasoned Executive Team



Manny Lakios President & Chief Executive Officer

- Appointed President and CEO of CVD January 2021
- Previously President and CEO at Sensor Electronic Technology, COO Imago Scientific, President Process Equipment Veeco
- 40 years of experience serving the aerospace, semiconductor, data storage, UVLED and optical device industries and holds multiple patents in equipment technology



Richard Catalano Executive Vice President & Chief Financial Officer

- CFO of CVD since August 2022
- Previously an audit partner at KPMG
- Served as leader of KPMG's Metro NY Healthcare and Life Sciences Practice and has over 35 years of experience as an audit professional



Max Shatalov Vice President of Engineering & Technology

- Joined CVD as VP of Engineering and Technology in April 2018
- Previously VP of Technology at Sensor Electronic Technology Inc.
- Over 20 years of experience in semiconductor research and devices, currently holding 120+ US patents



Jeff Brogan Vice President of Sales & Marketing

- VP of Sales & Marketing for CVD March 2021
- Previously President & CEO of MesoScribe Technologies Corp.
- Over 25 years experience serving aerospace and defense industries, strategic sales & marketing, advanced research & technology development, currently holding multiple US patents



Warren Cheesman Vice President of Manufacturing Operations

- VP of Manufacturing Ops at CVD since October 2022
- Previously VP of Engineering at iON Technology Solutions
- Over 25 years of management experience in the semiconductor, medical device and defense equipment sectors



Kevin Collins Vice President & General Manager SDC® Division

- General Manager at SDC since October 1999
- Previously employed by Stainless Design Corp. as Manager of Field Operations and Product Development Advisor
- Mr. Collins attended Columbia University School of Engineering and Applied Science.

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# Thank You!

PowderCoat 1104<sup>™</sup> Chemical Vapor Deposition System PVT200™ Physical Vapor Transport System

CVI 3500<sup>™</sup> Chemical Vapor Infiltration (CVI) System

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